

(11)Publication number:

09-255519

(43) Date of publication of application: 30.09.1997

(51)Int.CI.

A61K 7/00 7/02 A61K A61K 7/031 7/032 A61K 7/08 A61K 7/48 A61K

(21)Application number: 08-090485

(71)Applicant:

**NOEVIR CO LTD** 

(22)Date of filing:

19.03.1996

(72)Inventor:

**TERAI SHIN** 

## (54) ANTIBACTERIAL LOW IRRITATING COSMETIC MATERIAL

## (57) Abstract:

PROBLEM TO BE SOLVED: To obtain a cosmetic material manifesting an effective antibacterial effect, not only not showing a primary irritation or a sensitization to a skin, but also not giving au uncomfortable feeling such as a piercing pain, an irritat ing feeling and a prickling feeling on using the cosmetic material.

SOLUTION: This antibacterial low irritating cosmetic material contains one kind, or two or more kind selected from polyhydric alcohols and alkylethers of the polyhydric alcohols, and ond kind, or two or more kinds selected from extracts of plants having an antibacterial activity to begin with a ginkgo and a low striped bamboo (Sass albo-marginata). Since the antibacterial activity is synergistically enhanced by the simultaneous utilization of 0.01-20.0wt.% one kind or two or more kinds of the plant extracts in a system containing ≥ 5wt.% polyhydryl alcohol and the alkylether of the polyhydryl alcohol, and the irritating property to a skin or an uncomfortable feeling on use can markedly be reduced.

## **LEGAL STATUS**

[Date of request for examination]

18.05.2001

[Date of sending the examiner's decision of rejection]

10.05.2004

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[Date of extinction of right]

Copyright (C); 1998,2003 Japan Patent Office